

L Number	Hits	Search Text	DB	Time stamp
3	3	((mask adj blank) and scatter\$4 adj layer) and electron adj beam) and carbon	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/11 15:43
4	8	((mask adj blank) and scatter\$4 adj layer) and electron adj beam) and silicon	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/11 15:43
-	0	09/606679	USPAT; US-PGPUB	2004/05/11 09:08
-	0	"09606679"	USPAT; US-PGPUB	2003/04/06 18:10
-	1421	electron same beam same draw\$4 same mask	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/04/06 18:11
-	235	(electron same beam same draw\$4 same mask) and scatter\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/04/06 18:11
-	40	(electron same beam same draw\$4 same mask) same scatter\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/04/06 20:02
-	37	((electron same beam same draw\$4 same mask) same scatter\$4) and pattern	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/04/06 19:07
-	1	1999-435682.NRAN.	DERWENT	2003/04/06 19:02
-	0	11176720.URPN.	USPAT	2003/04/06 19:02
-	2	((("5466904") or ("5260151"))).PN.	USPAT; US-PGPUB	2003/04/06 19:07
-	5	electron same beam same draw\$4 same mask.ti.	USPAT; US-PGPUB	2003/04/06 19:13
-	5	((electron same beam same draw\$4 same mask) same scatter\$4) and stop	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/04/06 20:02
-	1095	electron same beam same draw\$4 same (mask reticle)	USPAT; US-PGPUB	2003/04/06 20:05
-	1512	electron same beam same draw\$4 same (mask reticle)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/04/07 08:46
-	14	(electron same beam same draw\$4 same (mask reticle)) and stress same heat\$4 same film	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/04/07 08:47
-	225	250/400	USPAT; US-PGPUB	2003/04/07 09:58
-	19	250/400 and stress	USPAT; US-PGPUB	2003/04/07 09:59
-	1219	electron same beam same draw\$4 same mask	USPAT; US-PGPUB	2004/04/21 15:09
-	1912	scatter\$4 adj layer	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/21 15:10

-	14	(electron same beam same draw\$4 same mask) and (scatter\$4 adj layer)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/04/21 15:10
-	30815	support\$4 adj layer	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/11 09:08
-	53	support\$4 adj layer and scatter\$4 adj layer	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/11 09:09
-	27	(support\$4 adj layer and scatter\$4 adj layer) and beam	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/11 09:12
-	11	(support\$4 adj layer and scatter\$4 adj layer) and (electron proton molec\$4 neutron energy ion) adj beam	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/11 10:03
-	2	(support\$4 adj layer and scatter\$4 adj layer) and (electron proton molec\$4 neutron energy ion) adj beam and mask adj blank	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/11 10:37
-	1651	mask adj blank	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/11 10:37
-	205	(mask adj blank) and scatter\$4	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/11 10:38
-	132	((mask adj blank) and scatter\$4) and electron adj beam	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/11 10:39
-	122	((mask adj blank) and scatter\$4) and electron adj beam) and pattern	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/11 13:42
-	8	((mask adj blank) and scatter\$4 adj layer) and electron adj beam) and pattern	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/05/11 15:43